Charge Dynamics in Thermally and Doping Induced Insulator-Metal Transitions of $(Ti_{1-x}V_x)_2O_3$

M. Uchida, ¹ J. Fujioka, ¹ Y. Onose, ^{1,2} and Y. Tokura ^{1,2,3}

¹Department of Applied Physics, University of Tokyo, Tokyo 113-8656, Japan

²Multiferroics Project, ERATO, Japan Science and Technology Agency (JST), Tokyo 113-8656, Japan

³Cross-Correlated Materials Research Group (CMRG), ASI, RIKEN, Wako 351-0198, Japan

(Received 21 May 2008; published 8 August 2008)

Charge dynamics of $(\text{Ti}_{1-x}V_x)_2\text{O}_3$ with x=0–0.06 has been investigated by measurements of charge transport and optical conductivity spectra in a wide temperature range of 2–600 K with the focus on the thermally and doping induced insulator-metal transitions (IMTs). The optical conductivity peaks for the interband transitions in the 3*d* t_{2g} manifold are observed in both the insulating and metallic states, while their large variation (by ~0.4 eV) with change of temperature and doping level scales with that of the Ti-Ti dimer bond length, indicating the weakened singlet bond in the course of IMTs. The thermally and V-doping induced IMTs are driven with the increase in carrier density by band crossing and hold doping, respectively, in contrast with the canonical IMT of correlated oxides accompanied by the whole collapse of the Mott gap.

DOI: 10.1103/PhysRevLett.101.066406 PACS numbers: 71.27.+a, 71.30.+h, 78.20.-e

The insulator-metal transition (IMT) has been an important issue of condensed matter physics [1]. In the conventional semiconductor, the IMT is achieved by a shift of the chemical potential due to chemical or electrostatic doping, where the electronic band structure is almost rigid in the course of IMT. Even in the metallic state, the carrier density is small and proportional to the amount of doping. In typical Mott transitions of correlated *d*-electron systems such as V_2O_3 [2] and $La_{1-x}Sr_xTiO_3$ [3], on the contrary, the Mott gap collapses with the temperature change or the chemical doping as a result of the reconstruction of the electronic structure on a large energy scale comparable to the Coulomb repulsion (~several eV) upon the IMT. The carrier number estimated by the Hall coefficient is large $(\sim 1/\text{site})$ compared with the dopant concentration in the metallic state. In the high- T_c cuprate system [4], the parent compound is a Mott insulator (to be precise, a charge transfer insulator), but the carrier number is comparable to the dopant concentration in the low-doping and lowtemperature region. One of the plausible scenarios for the origin of the doped-insulator-like feature in the normal state is the pseudogap formation due to the preformed singlet pairs or to the resonating valence bond (RVB) state [5].

Ti₂O₃ with an α -corundum structure [Fig. 1(a)] shows a unique IMT [6]. Nominally, there is one 3d electron per Ti site in Ti₂O₃. The nearest neighbor Ti ions along the c axis show dimerization in the crystal lattice and the two electrons on the Ti-Ti dimer form a singlet pair below the insulator-metal transition temperature $T_{\rm IM}$ (\sim 450 K). As temperature increases, the dimerization becomes weaker and the metallic state emerges. The low-temperature insulating state cannot be reproduced by the LDA calculation without explicit consideration of the on-site Coulomb correlation [7]. There are two possible scenarios to explain the IMT. One is the band-crossing scenario [8–10]; the IMT is

viewed as the transition from the dimerized insulator to the semimetal. If the singlet state is destabilized, the conducting e_g^{π} state may cross the Fermi energy. The other is the Mott transition [11]. In this scenario, the formation of the singlet state is compatible with the large on-site Coulomb repulsion, and the electronic structure is expected to be totally reconstructed on a large energy scale in the course of the Mott transition as observed in the optical conductivity spectra for a similar dimer system VO₂ [12]. It is known for Ti₂O₃ that the metallic state remains down to the lowest temperature when Ti ions are partially replaced by V ions [13]. To elucidate the origin of the IMTs in Ti₂O₃, we have investigated the thermally and doping induced

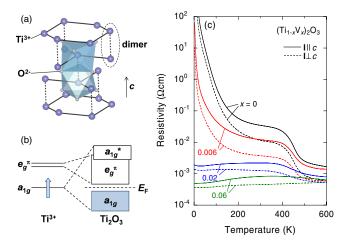


FIG. 1 (color online). (a) The corundum structure of Ti_2O_3 . The dashed lines represent the bonds in Ti-Ti dimer. (b) Schematic diagram for the proposed electronic structure in Ti_2O_3 [8]. For clarity, the notation e_g^π indicates both $e_g^{\pi^*}$ and e_g^π bands, as the $e_g^\pi - e_g^{\pi^*}$ splitting is small. (c) Temperature dependence of the resistivity in $(\text{Ti}_{1-x}\text{V}_x)_2\text{O}_3$ with x=0, 0.006, 0.02, and 0.06 for the current $\mathbf{I} \parallel c$ and $\mathbf{I} \perp c$.

IMTs in $(\text{Ti}_{1-x}\text{V}_x)_2\text{O}_3$ by optical and transport measurements. We observe the pseudogap feature in optical spectra even in the metallic state. Drude weight as well as the carrier number obtained by the Hall measurement at low temperature is proportional to the V concentration. These features are consistent with the picture of the doped band insulator, while the strong electron correlation on Ti site is essential for the robust singlet formation.

Single crystals of $(\text{Ti}_{1-x}\text{V}_x)_2\text{O}_3$ with x = 0, 0.006, 0.02,and 0.06 were prepared by the floating-zone method in Ar (93%) and H₂ (7%) atmosphere. The longitudinal and Hall resistivities were measured with the Physical Property Measurement System (PPMS) from Quantum Design. Polarized reflectivity in the temperature range of 10-600 K were measured between 0.01 and 5 eV. The measurements above room temperature were performed in the Ar/H₂ or vacuum atmosphere. Reflectivity spectra above 5 eV (up to 40 eV) were measured at room temperature with use of the synchrotron radiation at UV-SOR, Institute for Molecular Science. For the Kramers-Kronig analysis to deduce the optical conductivity, the spectrum above 40 eV was extrapolated by a ω^{-4} function, while below 0.01 eV the Hagen-Rubens relation and the constant reflectivity were assumed for metallic and insulating samples, respectively. Variation of these extrapolation procedures was confirmed to cause a negligible difference in the conductivity spectrum.

We show the temperature and doping dependences of the resistivity in Fig. 1(c). The resistivity for Ti_2O_3 shows a steep change around T_{IM} [6]. The resistivity for the current parallel to the c axis ($I \parallel c$) is about 3 times as high as that for $I \perp c$ [14]. For x = 0.006, the resistivity is much decreased but shows an insulating behavior. Above x = 0.02, the resistivity shows a metallic behavior, and for x = 0.06 the increase of the resistivity around T_{IM} is hardly observed. The anisotropy is observed even in the metallic state up to x = 0.06. The measurements of the Hall resistivity [15] and the Seebeck coefficient [14] indicate that V ion is nominally divalent in $(Ti_{1-x}V_x)_2O_3$ and thus the holes are introduced into the valence band [see also Fig. 3(d)].

In Figs. 2(a)-2(d), we show the optical conductivity spectra at various temperatures in $(Ti_{1-x}V_x)_2O_3$ with x=0 and 0.06 for $E \parallel c$ and $E \perp c$. For Ti_2O_3 , the $E \parallel c$ spectrum shows a clear gap structure of about 0.2 eV at the ground state (10 K). (Sharp spikes below 0.1 eV are due to the optical phonon modes [16].) The proposed electronic structure of Ti_2O_3 [8] is shown in Fig. 1(b). The t_{2g} levels in cubic symmetry split into the a_{1g} and e_g^{π} levels due to the trigonal ligand field. Furthermore, the a_{1g} band splits into the bonding a_{1g} and the antibonding a_{1g}^* bands mainly because of the hybridization within the Ti-Ti dimer. Two peaks around 1 and 3 eV are assigned to the $a_{1g} - e_g^{\pi}$ and $a_{1g} - a_{1g}^*$ interband transitions, respectively [17]. The $a_{1g} - a_{1g}^*$ dipole transition in the dimer is prohibited for

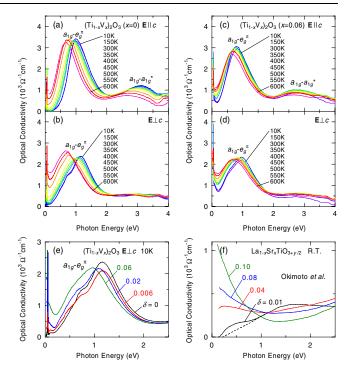


FIG. 2 (color online). Optical conductivity spectra at various temperatures in $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$ with x=0 for (a) $\mathbf{E} \parallel c$ and (b) $\mathbf{E} \perp c$, and with x=0.06 for (c) $\mathbf{E} \parallel c$ and (d) $\mathbf{E} \perp c$. Hole-doping dependence of the optical conductivity spectra in (e) $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$ and (f) $\mathrm{La}_{1-x}\mathrm{Sr}_x\mathrm{Ti}\mathrm{O}_{3+y/2}$ [3]. $\delta=x$ (or $\delta=x+y$) is nominal hole concentration, i.e., $\delta=1-n$ where n is the number of d electrons per Ti site. A dashed straight line in (f) indicates the hypothetical energy gap feature for $\delta=0$.

E $\perp c$. Because of the anisotropic extension of the a_{1g} orbital along the c axis, the $a_{1g} - e_g^{\pi}$ transition appears stronger for $\mathbf{E} \parallel c$ than for $\mathbf{E} \perp c$. With increasing temperature, these peaks markedly shift to lower energy by about 0.4 eV. Nevertheless, the clear band-gap feature remains to be observed in the whole temperature up to 600 K. For $\mathbf{E} \perp c$, a similar gap structure as well as the conspicuous low-energy shift of the interband transition is also observed. This result is incompatible with the theoretical picture for the IMT of Ti₂O₃ based on the Mott-Hubbard scheme [11]. For x = 0.06, a Drude peak is observed in the low-energy region, while the peak originating from the $a_{1g} - e_g^{\pi}$ transition is robust as in the hightemperature region of Ti₂O₃. In Fig. 2(e), we show the doping dependence of the ground-state optical conductivity spectra for $\mathbf{E} \perp c$ in $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$ at 10 K. With V doping, the peak energy of the $a_{1g} - e_g^{\pi}$ transition decreases, while the Drude response evolves below 0.2 eV. Nevertheless, the Drude weight remains small compared with the spectral weight of the interband transitions within the t_{2g} manifold.

In Figs. 3(a) and 3(b), the peak energies for the $a_{1g} - a_{1g}^*$ and $a_{1g} - e_g^{\pi}$ interband transitions for $\mathbf{E} \parallel c$ in $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$ are plotted as a function of temperature,

respectively. The shift of the peaks is clearly related with the change of the a_{1g} , e_g^{π} , and a_{1g}^{*} band positions. Both peak energies for $\mathbf{E} \parallel c$ in $\mathrm{Ti}_2\mathrm{O}_3$ are nearly temperature independent at low temperatures but show rapid decreases around $T_{\rm IM}$. The amount of the shift is comparable to, or even larger than, the band gap E_g (~0.2 eV) in Ti_2O_3 below room temperature. As x increases, the peak energy at low temperatures also reduces. However, the peak position around 600 K is almost independent of x, indicating that the conducting state above $T_{\rm IM}$ is common in nature irrespective of the V-doping level. In Figs. 3(c), we plot the peak energy E_p of the $a_{1g} - e_g^{\pi}$ transition for $\mathbf{E} \parallel c$ at 300 and 600 K in comparison with x dependence of the Ti-Ti dimer bond length $d_{\text{Ti-Ti}}$ estimated from the c/a ratio [18– 20]. Notably, the temperature and doping variation of the interband transition energy is approximately parallel to that of the $d_{\text{Ti-Ti}}$. The V doping induces the hole type carriers approximately at a rate of x/Ti site, as shown in Fig. 3(d). Therefore, the hole accumulation in the a_{1g} valence band appears to relax the Ti-Ti dimer bond, leading to the reduction of the energy gap between the a_{1g} and e_g^{π} bands. These results suggest that the local singlet formation on the

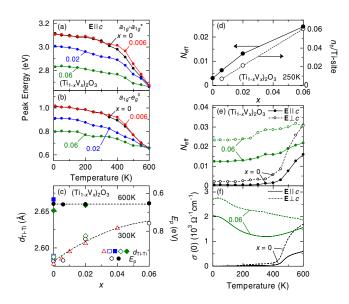


FIG. 3 (color online). Temperature variation of the peak energies for the interband transitions (a) $a_{1g} - a_{1g}^*$ and (b) $a_{1g} - e_g^\pi$ for $\mathbf{E} \parallel c$ in $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$. (c) Temperature and doping variation of the Ti-Ti dimer bond length $d_{\mathrm{Ti-Ti}}$ (triangles [18], squares [19], and diamonds [20]) reproduced from the structural data in the literature in comparison with the $a_{1g} - e_g^\pi$ ($\mathbf{E} \parallel c$) peak energy E_p (circles). Open and closed symbols represent the data at 300 and 600 K, respectively. Dashed lines for the peak energy are merely a guide to the eyes. (d) x dependence of the hole type carrier density n_h per Ti site and the effective number of the electrons N_{eff} at 0.2 eV for $\mathbf{E} \perp c$ as a measure of the Drude weight (see text). Temperature dependence of (e) the N_{eff} at 0.2 eV and (f) the conductivity $\sigma(0)$ in $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$ (x=0 and 0.06).

Ti-Ti dimer is responsible for the robust band gap but amenable to the thermal band-gap excitation and the hole doping.

To see the carrier dynamics in more detail, we show in Fig. 4 the low-energy part of the optical conductivity spectra in $(Ti_{1-x}V_x)_2O_3$ at various temperatures below and above $T_{\rm IM}$. At 600 K, the low-energy optical conductivity shows rather ω -flat and less x-dependent features both for $\mathbf{E} \parallel c$ and $\mathbf{E} \perp c$, indicating the incoherent carrier dynamics in the conducting state above $T_{\rm IM}$. For x=0, the spectral weight decreases with decreasing temperature and the conductivity shows a gap structure at low temperature. For the V-doped crystals, the spectral weight also decreases with decreasing temperature, but remains finite even at the lowest temperature. While for x = 0.006 and 0.02, the conductivity shows a broad maximum around several tens meV, which is typical of incoherent metal [21], the spectra for x = 0.06 shows a sharp Drude response. The difference between the dc and the lowest-energy optical conductivity is consistent with the incoherent response of the doped carriers and the expected energy variation of the

Figures 3(d) and 3(e) show the doping and temperature dependence of the effective number of electrons N_{eff} at

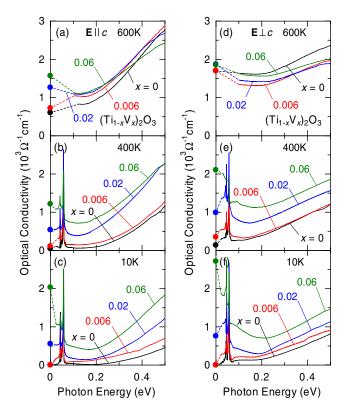


FIG. 4 (color online). Magnified view of the optical conductivity spectra below 0.5 eV in $(\mathrm{Ti}_{1-x}\mathrm{V}_x)_2\mathrm{O}_3$ at (a) 600 K, (b) 400 K, and (c) 10 K for the polarization $\mathbf{E} \parallel c$ and (d)–(f) those for $\mathbf{E} \perp c$ [23]. Closed circles represent the measured dc conductivity in each x. Dashed lines interpolating between the dc and optical conductivities are merely the guide to the eyes.

0.2 eV in $(\text{Ti}_{1-x}V_x)_2\text{O}_3$, respectively, as a measure of Drude weight. The N_{eff} is defined by the following relation:

$$N_{\rm eff} = \frac{2m_0 V}{\pi e^2} \int_0^{\omega_c} \sigma(\omega) d\omega. \tag{1}$$

Here m_0 , V, and ω_c (=0.2 eV) are the free-electron mass, the cell volume containing one Ti atom, and the cutoff energy adopted as the $a_{1g} - e_g^{\pi}$ gap energy, respectively. [The contribution of the optical phonon was subtracted in Figs. 3(d) and 3(e)] As seen in Fig. 3(d), the $N_{\rm eff}$ at 250 K is nearly proportional to the doping level x, as well as the hole density n_h . Thus, the metallic conductivity in the V-doped crystal is caused by the doped holes accumulated in the $a_{1\rho}$ valence band, whose concentration is proportional to x as in the doped semiconductor; the conventional Drude formula suggests that m^* (effective mass) $\sim 4m_0$ at low temperatures. The N_{eff} for Ti_2O_3 shows a sudden increase around $T_{\rm IM}$ [Fig. 3(e)] and its temperature dependence roughly agrees with that of the dc conductivity $\sigma(0)$ for both **E** $\parallel c$ and **E** $\perp c$ [Fig. 3(f)]. For x = 0.06, the $\sigma(0)$ increases with decreasing temperature below $T_{\rm IM}$, while the $N_{\rm eff}$ decreases monotonically. This can be explained by the temperature dependence of the scattering rate (or mobility) of the carriers in the metallic state. The $N_{\rm eff}$ values at 600 K suggest the effective carrier density as low as 0.06–0.09/Ti in the high-temperature conducting state.

The comparison of these results with those in Mott transition system is meaningful. We show in Fig. 2(f) the doping variation of the optical conductivity spectra in the typical Mott transition system $La_{1-x}Sr_xTiO_{3+y/2}$ (LSTO) reported by Okimoto et al. [3]. In LSTO, the large amount of the spectral weight is transferred from the high-energy Mott gap excitation to the low-energy Drude part in the course of the doping (x + y/Ti site) induced IMT. This behavior is quite contrastive with that in $(Ti_{1-x}V_x)_2O_3$ shown in Fig. 2(e). The coexistence of the pseudogap feature and the Drude peak with small spectral weight in $(Ti_{1-r}V_r)_2O_3$ is consistent with the picture of the doped band insulator. Nevertheless, the doping induced lowenergy shift of the whole interband transition bands [see Figs. 3(a) and 3(b)] is appreciable. Thus, the band gap arising from a_{1g} -electron singlet formation in the bond dimer is critically affected by the hole-doping level and the thermal gap excitation above $T_{\rm IM}$. The thermally induced IMT in Ti₂O₃ can be interpreted with band-crossing picture via the weakened singlet bond by the thermal gap excitation. The recent LDA + DMFT calculation suggests that the effective bandwidth is reduced by the electron correlation, which stabilizes the dimerized state as well

In summary, we have investigated the optical and transport properties for $(\text{Ti}_{1-x}\text{V}_x)_2\text{O}_3$ in the wide temperature range of 2–600 K. We identify that in the optical conduc-

tivity spectra the peaks due to the interband transitions remain to be observed in the thermally and V-doping induced metallic state. The variation of the gap energy in the course of the IMT nearly scales with that of the Ti-Ti bond length reflecting the singlet-bond strength. The Drude component is small compared with the weight of the interband transition bands and proportional to x, as well as the carrier number obtained by the Hall coefficient, whereas the magnitude of the band gap is sensitively affected by the thermal gap excitation and the hole doping. These observations are contrasted with the case of the canonical Mott transition in correlated electron systems, which accompanies the large spectral weight transfer from the gap excitation to the Drude component.

This work was partly supported by Grants-In-Aid for Scientific Research (Grants No. 16076205, No. 19684011, No. 20340086, No. 20046004) from the MEXT of Japan.

- [1] M. Imada, A. Fujimori, and Y. Tokura, Rev. Mod. Phys. 70, 1039 (1998).
- [2] M. J. Rozenberg et al., Phys. Rev. Lett. 75, 105 (1995).
- [3] Y. Okimoto et al., Phys. Rev. B **51**, 9581 (1995).
- [4] T. Timusk and B. Statt, Rep. Prog. Phys. 62, 61 (1999).
- [5] P. A. Lee, N. Nagaosa, and X.-G. Wen, Rev. Mod. Phys. 78, 17 (2006).
- [6] F. J. Morin, Phys. Rev. Lett. 3, 34 (1959).
- [7] L. F. Mattheiss, J. Phys. Condens. Matter 8, 5987 (1996).
- [8] L. L. Van Zandt, J. M. Honig, and J. B. Goodenough, J. Appl. Phys. 39, 594 (1968).
- [9] H. J. Zeiger, T. A. Kaplan, and P. M. Raccah, Phys. Rev. Lett. 26, 1328 (1971).
- [10] H. J. Zeiger, Phys. Rev. B 11, 5132 (1975).
- [11] A. Tanaka, J. Phys. Soc. Jpn. 73, 152 (2004).
- [12] M. M. Qazilbash et al., Phys. Rev. B 74, 205118 (2006).
- [13] G. V. Chandrashekhar et al., Mater. Res. Bull. 5, 999 (1970).
- [14] S. H. Shin et al., Phys. Rev. B 8, 1364 (1973).
- [15] J. M. Honig and T. B. Reed, Phys. Rev. 174, 1020 (1968).
- [16] G. Lucovsky, R. J. Sladek, and J. W. Allen, Phys. Rev. B 16, 5452 (1977).
- [17] S. S. M. Lu, F. H. Pollak, and P. M. Raccah, Phys. Rev. B 17, 1970 (1978).
- [18] C. E. Rice and W. R. Robinson, J. Solid State Chem. 21, 145 (1977).
- [19] C. N. R. Rao, R. E. Loehman, and J. M. Honig, Phys. Lett. A 27, 271 (1968).
- [20] J. J. Capponi et al., Solid State Commun. 20, 893 (1976).
- [21] K. Takenaka et al., Phys. Rev. B 65, 092405 (2002).
- [22] A.I. Poteryaev, A.I. Lichtenstein, and G. Kotliar, Phys. Rev. Lett. **93**, 086401 (2004).
- [23] At 600 K, we could not measure the far-infrared reflectivity below 0.1 eV due to the limitation of our experimental instruments.